Best paper honors

Two RIT students recently earned honors for best student paper at national conferences. Neal Lafferty, a microsystems engineering Ph.D. student, was recognized for his paper, "Mask Enhancement Using an Evanescent Wave Effect," co-written with Bruce Smith, Intel Professor of Microelectronic Engineering and two others, at Advanced Lithography 2007, sponsored by the International Society for Optical Engineering, Feb. 27-March 2, in San Jose, Calif. It marked the second time an RIT microsystems engineering doctoral student earned the award. Yongfa Fan was honored in 2004.

Brian McShane, a 2006 graduate of the Environmental, Health and Safety Management Masters of Science degree program, was honored for his paper, "Nanotechnology: Is There Cause for Concern?" in the American Society of Safety Engineers’ annual professional paper competition. The article was based on McShane’s thesis. The award will be presented in Orlando, Fla. later this year.